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## FACSIMILE COVER SHEET

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| To Examiner: Thanhha S. Pham<br><br>Technology Center 2800 | Total Pages Sent: 12<br><br>(including cover sheet) |
| Facsimile Number: (571) 273-8300                           | Transmission Date: September 28, 2005               |

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant: Schwalbe, *et al.* Docket No.: INF-119  
 Serial No.: 10/724,141 Art Unit: 2813  
 Date Filed: December 1, 2003  
 TITLE: Method For Patterning Dielectric Layers On Semiconductor Substrates

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- Certification of Facsimile Transmission (1 page)
- Amendment (11 pages)

Respectfully submitted,

*Kristy Engeldahl*

Kristy Engeldahl  
 Legal Assistant

Confirmation Respectfully Requested

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For: Method For Patterning Dielectric Layers On Semiconductor Substrates

Mail Stop Amendment  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

AMENDMENT

Dear Sir:

The following amendments and remarks are presented in response to the Examiner's Office Action mailed June 28, 2005. Please amend the above-referenced application as follows.

INF-119

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Amendment